

	<b>Titl</b>	<b>Curr nt OR</b>	<b>Curr nt XRef</b>
<b>1</b>	<b>Vibration isolation apparatus using magnetic levitation devices</b>	<b>248/638</b>	<b>248/550</b>
<b>2</b>	<b>Active vibration isolator and exposure apparatus with the active vibration isolator, device manufacturing method</b>	<b>248/550</b>	<b>73/663</b>
<b>3</b>	<b>Method of recording a vibration isolation system</b>	<b>700/63</b>	<b>248/550; 248/638; 700/45; 700/60</b>
<b>4</b>	<b>Reference table tilting mechanism</b>	<b>248/542</b>	<b>248/346.01</b>
<b>5</b>	<b>Base stabilization system</b>	<b>250/548</b>	<b>248/550; 355/53</b>
<b>6</b>	<b>Anti-vibration system in exposure apparatus</b>	<b>355/53</b>	<b>248/550; 248/648</b>
<b>7</b>	<b>Vibration isolation apparatus for stage</b>	<b>355/53</b>	<b>188/267; 188/278; 248/550; 248/638; 267/136; 267/140.14; 267/140.15; 355/33</b>
<b>8</b>	<b>Anti-vibration apparatus, exposure apparatus using the same, device manufacturing method, and anti-vibration method</b>	<b>267/136</b>	<b>188/378; 248/550; 378/210</b>
<b>9</b>	<b>Active vibration isolator, exposure apparatus, xp sur meth d and d vic manufacturing m th d</b>	<b>188/378</b>	<b>248/550; 267/136; 73/662</b>

	<b>Titl</b>	<b>Curr nt R</b>	<b>Curr nt XR f</b>
<b>10</b>	<b>Anti-vibration apparatus and exposure apparatus using the same</b>	<b>248/550</b>	<b>248/638; 702/56</b>
<b>11</b>	<b>Anti-vibration apparatus and anti-vibration method thereof</b>	<b>188/378</b>	<b>248/550; 267/136</b>
<b>12</b>	<b>Anti-vibration apparatus and method</b>	<b>700/280</b>	<b>248/550; 318/651</b>
<b>13</b>	<b>Vibration isolator and exposure apparatus</b>	<b>355/53</b>	<b>248/550; 248/638; 356/400</b>
<b>14</b>	<b>Vibration isolator and method of isolating vibration</b>	<b>248/550</b>	<b>248/638; 355/53; 700/280; 702/56</b>
<b>15</b>	<b>Tilt mechanism for wafer cassette</b>	<b>156/345.12</b>	<b>118/500; 118/728; 118/729; 248/133; 248/178.1; 269/309; 414/935; 414/936; 414/937; 414/938; 414/940</b>
<b>16</b>	<b>Active anti-vibration apparatus</b>	<b>248/550</b>	<b>188/267; 248/638; 267/136</b>

	<b>Title</b>	<b>Curr nt OR</b>	<b>Curr nt X R f</b>
17	Adaptive tuned vibration absorber, system utilizing same and method of controlling vibration therewith	188/378	188/380; 244/1N; 244/129.1; 244/17.27; 244/54; 248/550; 267/136; 267/140.15; 381/71.1; 415/119
18	Centrifugal delayed resonator pendulum absorber	188/379	248/550; 248/562
19	Vibration cancellation apparatus	248/550	248/638
20	Vibration removing apparatus and method thereof	188/378	248/550; 267/136
21	Control apparatus for vertical vibration elimination table	248/550	108/136; 188/378
22	Method and apparatus for actively adjusting and controlling a resonant mass-spring system	188/378	248/550; 267/136
23	Dual quad flexure scanner	250/442.11	248/179.1; 33/568
24	Device for supporting and positioning a microscope	248/325	248/122.1
25	Active vibration control systems	248/550	244/17.11 248/550;
26	Active vibration isolation system	267/136	267/64.16; 318/460

	<b>Titl</b>	<b>Curr nt OR</b>	<b>Curr nt XR f</b>
<b>27</b>	<b>Controllable damper</b>	<b>52/1</b>	<b>244/75A; 248/638; 267/140.11; 52/167.1; 52/167.2</b>
<b>28</b>	<b>Active vibration isolation system</b>	<b>267/136</b>	<b>248/550; 267/64.16; 318/460</b>